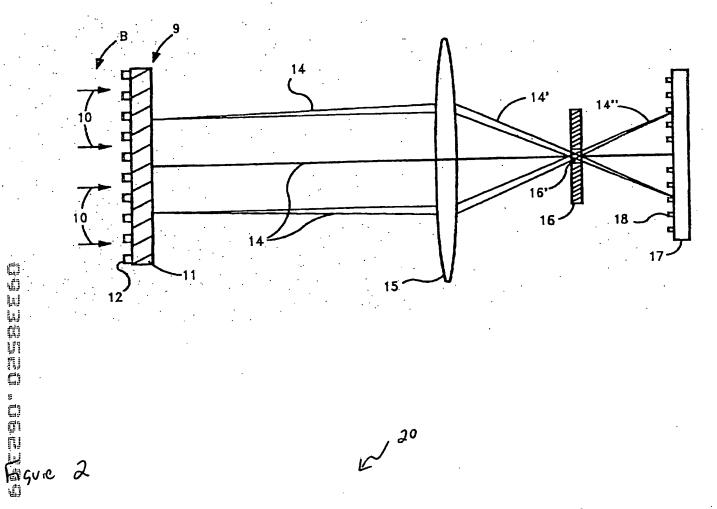
Figure 1



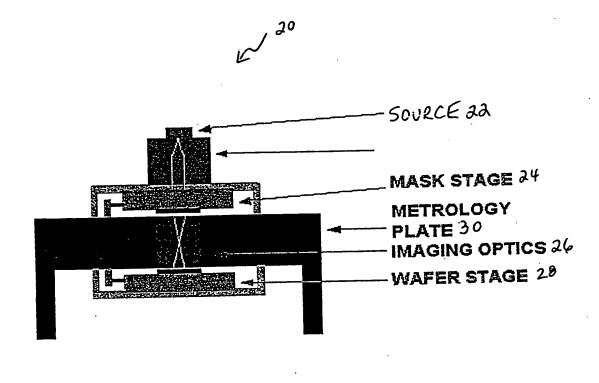


Figure 3

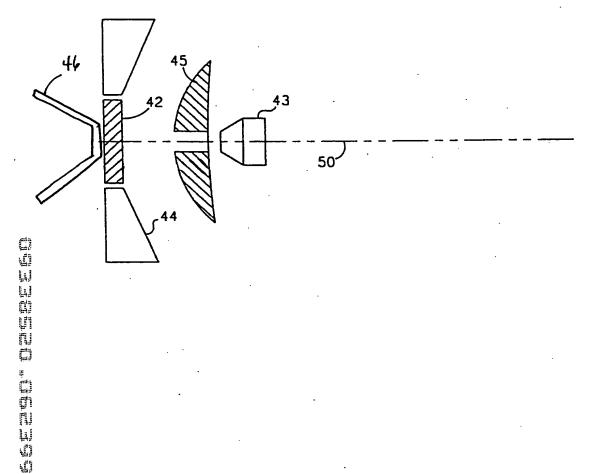


Figure 5 emissive layer 116 buffer Substrate 112 46 100 Figure 4 prepare substrate surface for deposition 200 deposit on substrate 300 deposit emissive layer buffer.

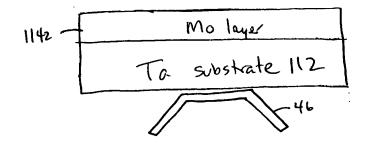
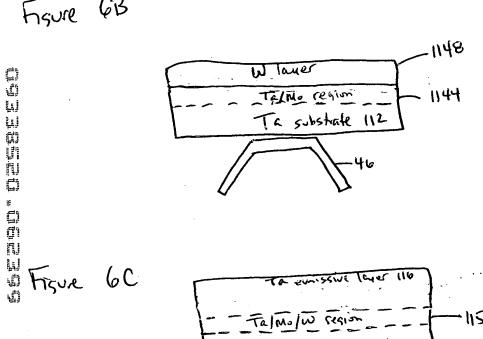
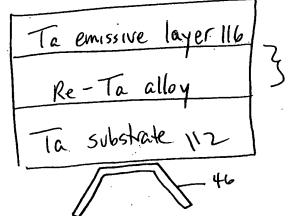


Figure 6B



Ta Substale 112

W) IIO



3 buffer film 113

Figure 8A

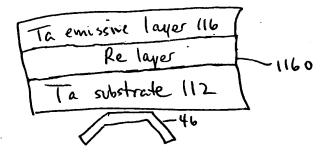


Figure 8B

Ta emissive layer 11b

Ta-Re ulloy

Ta substate 112

y-3-